Controlling the spin polarization of the electron current in a semimagnetic resonant-tunneling diode

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(Received 18 June 2004; revised manuscript received 11 October 2004; published 23 March 2005)

The spin filtering effect of the electron current in a double-barrier resonant-tunneling diode (RTD) consisting of $Zn_{1-x}Mn_xSe$ semimagnetic layers has been studied theoretically. The influence of the distribution of the magnesium ions on the coefficient of the spin polarization of the electron current has been investigated. The dependence of the spin filtering degree of the electron current on the external magnetic field and the bias voltage has been obtained. The effect of the total spin polarization of the electron current has been predicted. This effect is characterized by total suppression of the spin-up component of electron current, which takes place when the Fermi level coincides with the lowest Landau level for spin-up electrons in the RTD semimagnetic emitter.

DOI: 10.1103/PhysRevB.71.125325

PACS number(s): 75.50.Pp, 72.25.Dc, 72.25.Hg, 72.10.-d

I. INTRODUCTION

Spin-polarized ballistic electron transport in resonanttunneling semimagnetic semiconductor nanostructures attracts considerable attention of the researchers developing the fundamentals of spintronics.¹⁻⁸ This transport is also associated with the search for effective sources of the spinpolarized current which can be controlled using a constant magnetic field **B** as well as by means of a bias voltage V_a . Resonant-tunneling semimagnetic nanostructures are characterized by the high degree of the current spin polarization due to the *sp-d* exchange interaction between the conduction electrons and localized electrons of the magnetic ions belonging to the semimagnetic semiconductors.9-11 In a magnetic field **B**, this interaction gives rise to the giant Zeeman splitting of the electron energy levels. As a result, the electrons with spins oriented along **B** (spin-up electrons) and against **B** (spin-down electrons) move in different potential fields and have different transmission coefficients through the resonant-tunneling semimagnetic semiconductor nanostructures. Therefore, spin filtering of the electron current occurs even in moderate magnetic fields, and the electrons with a certain spin direction dominate in the current. The presence of the spin filtering of the electron current can be detected by its injection into a light-emitting diode and by the measurement of the electromagnetic radiation of the circular polarization.12,13

The idea of using semimagnetic semiconductors for spin filtering of the electron current has been proposed in Ref. 4. It was shown that the electron current flowing through a semimagnetic semiconductor layer in a constant magnetic field of 2-4 T displays a high degree of spin polarization. In Ref. 5, the dependences of the coefficient of current spin polarization on the thickness of the semimagnetic layer and the bias voltage have been investigated. In Refs. 6 and 7, the results of Refs. 4 and 5 have been summarized for the case of a nanostructure consisting of two semimagnetic semiconductor layers separated by a nonmagnetic layer. In these papers, along with the study of voltage-current characteristics of the nanostructure, the influence of the thicknesses of semimagnetic layers⁶ and operating temperatures⁷ on the value of the coefficient of the current spin polarization has been investigated.

Later, it was shown that the degree of the current spin polarization can be enhanced if the resonant-tunneling nanostructure has semimagnetic contacts.⁸ This is related to the fact that the conduction band edge of a semimagnetic emitter in the magnetic field **B** is spin dependent. In this case, the number of spin-down electrons in the emitter exceeds the number of spin-up electrons. As a result, spin-down electrons play the determining role in the current flowing through the resonant-tunneling nanostructure with semimagnetic contacts. Thus, the spin-dependent shift of the conduction band edge of the semimagnetic emitter and the spin-dependent electron transmission through semimagnetic layers lead to a significant increase in the coefficient of current spin polarization in fully semimagnetic resonant-tunneling nanostructures.

In this paper new results are presented on the theory of the effect of the electron current spin filtering in a doublebarrier resonant-tunneling diode (RTD) based on a $Zn_{1-x}Mn_xSe$ semimagnetic semiconductor. The choice of this semimagnetic semiconductor is related to the presence of an RTD in which the emitter, collector, and quantum well consist of this semiconductor material.³ In contrast to Ref. 8, we assume that all RTD layers are semimagnetic. Moreover, in our paper the value of the electron current density and the coefficient of current spin polarization are determined taking into account the influence of the bias voltage V_a on the coefficient of the electron transmission through the RTD.

The dependencies of the electron current density and the coefficient of the current spin polarization on the constant magnetic field **B** as well as on a bias voltage V_a are studied for different spatial distributions of magnetic ions in the RTD and for different values of the Fermi level in the RTD emitter. The occurrence of the total polarization of the electron



FIG. 1. (a) The $Zn_{1-x}Mn_xSe$ double-barrier resonant-tunneling semimagnetic nanostructure (RTD) and (b) its spin-dependent conduction band profile in the nonzero bias voltage.

current has been predicted. Total polarization takes place when the Fermi level coincides with the lowest Landau level for spin-up electrons in the RTD semimagnetic emitter.

II. THEORETICAL MODEL

We assume that the RTD (including its emitter and collector) consists of $Zn_{1-x_j}Mn_{x_j}Se$ layers with different Mn concentrations $x_j = \{x_1, x_2, x_3, x_4, x_5\}$ [Fig. 1(a)]. The region $z < z_1$ is an RTD emitter and the region $z > z_4$ is an RTD collector. We assume that the emitter and collector are *n*-doped. The external magnetic field **B** is directed along the *z* axis. The bottoms of the conduction bands for the spin-down and spin-up electrons are shown by the solid and dashed lines correspondingly in Fig. 1(b). The values of $L_i = z_{i+1} - z_i$ (*i*=1,2,3) are the thicknesses of two potential barriers (L_1 and L_3) and the potential well (L_2) of the RTD. The value E_F is the Fermi level in the emitter and collector.

As is well known, the band gap of semimagnetic semiconductors depends on the Mn concentration.^{9,14–16} Therefore, at the boundary between two semimagnetic semiconductors with different Mn concentrations, an offset of the band gap takes place. In this case, one part of this offset falls at the conduction band offset and the other one falls at the valence band offset.¹⁴ At low temperatures the band gap E_{gj} of the semimagnetic semiconductors depends slightly on x_j in the range $x_3 < 0.065$.^{9,14–16} Therefore, to obtain the dependence of the conduction band edge $E_{cj}(x_j)$ of the semimagnetic semiconductor, we use the following empirical formula which describes the experimental dependencies in Ref. 14:

$$E_{cj}(x_j) = \begin{cases} E_g(0), & x_j < 0.065, \\ E_0 + (1 - \text{VBO})x_j \Delta E_g, & x_j > 0.065. \end{cases}$$
(1)

Here $E_g(0)=2.822$ eV is the band gap of ZnSe, VBO is the valence band offset, $\Delta E_g=0.4141$ eV, and E_0 is the fitting

parameter [for each value of VBO, it is determined in such a way that at the point $x_j=0.065$ the function $E_{cj}(x_j)$ is continuous].

In the external magnetic field **B**, the conduction band edge of the semimagnetic semiconductor is spin dependent due to the effect of the giant Zeeman splitting of the electron energy levels.^{9,10} The value of the spin-dependent shift $\epsilon_{j\sigma_z}(B)$ of the conduction band edge of the semimagnetic semiconductor is equal to the value of the energy of the *sp-d* exchange interaction between the conduction electrons and localized electrons of the magnetic Mn ions,

$$\boldsymbol{\epsilon}_{j\sigma_z}(B) = -\sigma_z x_j^{eff} N_0 \alpha \langle S_{zj} \rangle, \qquad (2)$$

where $\sigma_z = \pm 1/2$ (or \uparrow, \downarrow) is the spin quantum number; $x_j^{eff} = x_j(1-x_j)^{12}$ is the effective concentration of Mn ions;⁴⁻⁸ $N_0\alpha$ is the *sp-d* exchange constant for conduction electrons; and $\langle S_{zj} \rangle$ is the thermal average of the Mn spin component along the magnetic field **B**:

$$\langle S_{zj} \rangle = -SB_S(g_{Mn}\mu_B SB/kT_i^{eff}).$$
(3)

Here B_S is the modified Brillouin function for the total spin quantum number of Mn ions; S=5/2; $g_{Mn}=2$ is g-factor of the spectroscopic splitting for Mn-*d*-electrons; μ_B is the Bohr magneton; $T_j^{eff}=T+T_j^{AF}$ is the effective temperature; *T* is the lattice temperature of semimagnetic semiconductors; and T_j^{AF} is the phenomenological parameter. The parameters, x_j^{eff} and T_j^{AF} , are required by the necessity to take into account the antiferromagnetic interaction between the Mn ions.

Thus, the conduction band edge of semimagnetic semiconductors $E_{cj\sigma_z}$ in the magnetic field **B** is determined by the following formula:

$$E_{cj\sigma_z} = E_{cj} + \epsilon_{j\sigma_z}(B). \tag{4}$$

We consider sufficiently high magnetic fields for which the Landau quantization of transverse motion of electrons is important. Then the electron energy in each layer of the considered RTD has the following form:

$$E_{j\sigma_z} = E_{cj\sigma_z} + \left(l + \frac{1}{2}\right)\hbar\omega_c + \sigma_z g^* \mu_B B + E_z.$$
 (5)

Here l=0,1,2,... is the Landau level quantum number; $\omega_c = eB/cm^*$ is the electron cyclotron frequency; $E_z = \hbar^2 k_z^2/2m^*$ is the electron energy connected with their motion along the RTD (k_z is the electron wave vector along z direction); m^* is the effective electron mass (we assume a single electron mass throughout all RTD layers); and g^* is the zone electron g-factor.

Taking into account expression (4), the electron energy in each RTD layer can be written in the following form,

$$E_{j\sigma_z} = E_{cj} + \left(l + \frac{1}{2}\right)\hbar\omega_c + \sigma_z g_j^{eff} \mu_B B + E_z,\tag{6}$$

where

$$g_j^{eff} = g^* + x_j^{eff} N_0 \alpha SB_S(g_{Mn} \mu_B SB/kT_j^{eff}) / \mu_B B.$$
(7)

The average current density through the RTD created by electrons with σ_z polarization in the magnetic field *B* at the finite temperature *T* is determined by the following expression:^{5–7}

$$J_{\sigma_{z}} = J_{0}B\sum_{l=0}^{\infty} \int_{0}^{\infty} T_{\sigma_{z}}(E_{z}, B, V_{a}) \{f[E_{z} + (l + \frac{1}{2})\hbar\omega_{c} + \sigma_{z}g_{1}^{eff}\mu_{B}B] - f[E_{z} + (l + \frac{1}{2})\hbar\omega_{c} + eV_{a} + \sigma_{z}g_{5}^{eff}\mu_{B}B]\}dE_{z},$$
(8)

where $T_{\sigma_z}(E_z, B, V_a)$ is the electron transmission coefficient through the RTD; $J_0 = e^2/h^2c$; and $f(E) = 1/\{1 + \exp[(E - E_F)/kT]\}$ is the Fermi function.

The total current density J_t through the RTD is $J_{\uparrow}+J_{\downarrow}$ and the coefficient of the current spin polarization P is

$$P = \frac{J_{\perp} - J_{\uparrow}}{J_{\perp} + J_{\uparrow}}.$$
(9)

To find $T_{\sigma_z}(E_z, B, V_a)$ we use the Airy's-function-based transfer-matrix method.¹⁷ This allows us to calculate J_{σ_z} numerically for arbitrary values of V_a . In the following we use these specific values of the RTD parameters: $m^*=0.16m_0$ (m_0 is the free electron mass), $g^*=1.1$; $N_0\alpha=0.26$ eV; T=4.2 K; $T_{eff}^j=2$ K; $L_1=L_3=5$ nm; and $L_2=9$ nm. Note that the thicknesses of the quantum well and two barriers of the RTD correspond to the physical semimagnetic RTD with nonmagnetic barriers, whose properties were investigated experimentally in Ref. 3.

III. NUMERICAL RESULTS AND DISCUSSION

The spin-filtering effect of the electron current becomes most clearly apparent when the energy of the *sp-d* exchange interaction is maximal. Considering this energy as a function of x_j , it is easy to show from formula (2) that it is maximal at $x_j=x_m=1/13 \approx 0.077$. Later on we will consider the case when the Mn concentration in the emitter and collector of the RTD is equal to this value, that is, $x_1=x_5=x_m$. This allows us to obtain the maximal value of the spin-dependent shift of the conduction band edge of the emitter and collector. To create the potential profile inherent in double-barrier RTDs, it is required that the concentration of Mn ions in the two barriers (x_2 and x_4) is larger than in the emitter (x_1), collector (x_5), and the potential well (x_3). We assume that $x_2=x_4=0.25$, and x_3 is changed from $x_3=0$ to $x_3=x_m$.

A. The spin-dependent RTD conduction band profile at the zero bias voltage

Figure 2 shows the dependence of the energy $E_{c3\sigma_z}$ of the conduction band edge of quantum well (we choose the zero of the energy to be at the conduction band edge $E_{c1\sigma_z}$ of the RTD emitter) on the Mn concentration x_3 for three values of B=2,3,4 T (the solid lines correspond to the spin-down electrons and the dashed lines correspond to the spin-up electrons). It is seen from Fig. 2 that with increasing *B*, the difference in the position of the conduction band edge of the RTD quantum well for the spin-up and spin-down electrons increases. At a fixed value of *B*, the largest difference in the position of the largest spin splitting of the electron levels in the RTD quantum well occurs, at $x_3=0$. We emphasize that this statement is related to the fact that we measure



FIG. 2. The dependence of the conduction band edge of the RTD quantum well on the Mn ion concentration x_3 for spin-down (solid lines) and spin-up (dashed lines) electrons at $x_1=x_5=x_m$ = 0.077, $x_2=x_4=0.25$ for B=2,3,4 T.

the energy $E_{c3\sigma_z}$ of the conduction band edge of quantum well from the energy $E_{c1\sigma_z}$ of the conduction band edge of the emitter. As far as the RTD emitter has a nonzero Mn-ion concentration ($x_1=x_m=0.077$) and the energy $E_{c1\sigma_z}$ is spin dependent, the relative position of the energy $E_{c3\sigma_z}$ is defined by the electron spin direction.

Figure 3 shows the zero bias voltage RTD potential profile (the energy is measured from the spin split conduction band edge of the emitter) for spin-down electrons (solid lines) and for spin-up electrons (dashed lines) for (a) $x_3=0.0$ and (b) $x_3=0.05$ at B=4 T. One can see that for spin-up electrons the barriers are smaller and the quantum well is deeper than for spin-down electrons. Consequently, the energy levels in the quantum well lie deeper for spin-up electrons than for the spin-down electrons. It is obvious that with decreasing x_3 , the difference in the potential profile for spin-up and spin-down electrons increases, and the effect of electron current spin filtering becomes more apparent.

B. Magnetic field dependencies of the RTD current spin polarization

In Fig. 4 the dependencies of $J_{\uparrow}(V_a)$, $J_{\downarrow}(V_a)$, $J_t(V_a)$ (the left axis of ordinates) and $P(V_a)$ (the right axis of ordinates) are shown at (a) B=2 T and (b) B=4 T for $x_3=0.0$ and $E_F=10$ meV. It is seen from these figures that there are two current density peaks in the curves $J_{\uparrow}(V_a)$ and $J_{\downarrow}(V_a)$. With increasing *B*, the values of the peaks of $J_{\downarrow}(V_a)$ increase and for $J_{\uparrow}(V_a)$ they decrease. This is concerned with the fact that $J_{\sigma_z}(B)$ depends not only on the number N_{σ_z} of the Landau levels lying under the Fermi level but on the value of degeneracy of the Landau levels which is determined by the ratio $N_B=AeB/hc$ (*A* is the RTD area). The increase in *B* causes the decrease in N_{σ_z} and the increase in N_B . The first circumstance leads to the decrease in $J_{\sigma_z}(B)$ depends on the



FIG. 3. The zero bias voltage RTD potential profile for spindown electrons (solid lines) and for spin-up electrons (dashed lines) at B=4 T, $x_1=x_5=x_m=0.077$, $x_2=x_4=0.25$ for (a) $x_3=0.0$ and (b) $x_3=0.05$.

factor which is dominant. For the relatively small values of *B* which we have considered we have $N_{\downarrow} \ge N_{\uparrow}$. Therefore, for the spin-down electrons the main factor determining the peak value of the $J_{\downarrow}(B)$ is the increase in N_B with increasing *B*. As a result $J_{\downarrow}(B)$ is the increasing function of *B*, in spite of the minor decrease in N_{\downarrow} . For the spin-up electrons there are only several Landau levels under the Fermi level and the decrease in their number even by unity leads to the considerable decrease in $J_{\uparrow}(B)$, in spite of the increase in N_B . So $J_{\uparrow}(B)$ is the decreasing function of *B*. Note that the values of the peaks of the total current density $J_t(V_a)$ increase when *B* increases.

The dependencies of $P(V_a)$ are non-monotone functions and the values of the peaks of *P* rise with increasing *B* as well. The low-voltage range is of interest, in which $P \approx 1$ for the relatively small value of B=2 T. In Fig. 4, the presence of two peaks of the current densities $J_{\downarrow}(V_a)$ and $J_{\uparrow}(V_a)$ corresponds to the two lowest resonant spin splitting electron energy levels in the RTD quantum well. In this case, as the



FIG. 4. $J_{\uparrow}(V_a)$, $J_{\downarrow}(V_a)$, $J_t(V_a)$ (the left axis of ordinates) and $P(V_a)$ (the right axis of ordinates) at (a) B=2 T and (b) B=4 T for $x_3=0.0$, $E_F=10$ meV.

bias voltage increases, the resonant electron transmission takes place, from the beginning, for the first lowest electron energy level in the quantum well and then for the second electron energy level. Note that the shape of the first peak in $J_t(V_a)$ has interesting features such as at B=2 T the current density peak is split and at B=4 T there are kinks. This is due to both the presence of the spin splitting of the electron energy levels in the quantum well and the quantization of the transverse electron motion (the presence of the Landau levels).

A note should be made concerning the physical phenomena determining the shape of the above-mentioned dependencies $J_t(V_a)$ and $P(V_a)$. For this reason we plot $T_{\perp}(E_z)$ [Fig. 5(a)] and $T_{\uparrow}(E_z)$ [Fig. 5(b)] for the different values of the voltage bias V_a for B=4 T and $x_3=0.0$ (the numbers next to the curves show the corresponding values of V_a in volts).

There are resonant peaks with unit peak-value in $T_{\downarrow}(E_z)$ and $T_{\uparrow}(E_z)$ for $V_a=0$ [in view of the chosen scale in Fig. 5, these curves show only the region of the first resonant peak both for $T_{\downarrow}(E_z)$ and for $T_{\uparrow}(E_z)$]. Due to the fact that the depth of the potential well depends significantly on the electron spin, the resonant peaks of $T_{\downarrow}(E_z)$ and $T_{\uparrow}(E_z)$ strongly differ in location. With increasing V_a the resonant peaks of $T_{\downarrow}(E_z)$ and $T_{\uparrow}(E_z)$ shift in the low-energy region, and their peak



FIG. 5. (a) $T_{\downarrow}(E_z)$ and (b) $T_{\uparrow}(E_z)$ for the different values of the voltage bias V_a at B=4 T and $x_3=0.0$ (the numbers next to the curves show the corresponding values of V_a in volts).

values decrease. In Figs. 5 and 6 the dotted lines show the values of

$$E_{zm}^{\sigma_z}(l) = E_F - \frac{1}{2}\hbar\omega_c - \sigma_z g_1^{eff} \mu_B B, \qquad (10)$$

which are the maximal values of the longitudinal electron energy E_{z} for each Landau level *l*. The electrons located at Landau level l pass through the RTD when $E_{zm}^{\sigma_z}(l) > 0$. For $\sigma_{z}=1/2$, this condition is fulfilled only for l=0, but at $\sigma_z = -1/2$ it holds for $l = 0, \dots, 5$. With increasing V_a the current through the RTD occurs as soon as the first resonant peak of T_{σ_z} intersects the line $E_z = E_{zm}^{\sigma_z}(0)$ for the Landau level, l=0. For spin-down electrons this takes place at $V_a = 0.002$ V and for the spin-up electrons it occurs at V_a =0.0026 V. It is seen from Fig. 5(a) that with increasing V_a the resonant peak of $T_{\parallel}(E_z)$ shifts towards the low-energy region. In this case, the resonant peak decreases in magnitude and successively intersects the lines $E_z = E_{zm}^{\sigma_z}(l)$. At each intersection, the current density J_{\perp} increases at the expense of the electrons located at the corresponding Landau levels l, and a kink in $J_{\parallel}(V_a)$ occurs. On the other hand, the decrease



FIG. 6. The bias-voltage dependence of the $E_{zp}^{\sigma_z}$ locations of two resonant peaks in the dependencies $T_{\downarrow}(E_z)$ (solid lines) and $T_{\uparrow}(E_z)$ (dashed lines) for B=4 T and $x_3=0.0$.

in the magnitude of the resonant peak of T_{\perp} leads to a decrease in J_{\downarrow} . At a fixed value of V_a , the magnitude of $T_{\downarrow}(E_z)$ decreases so much that electrons with all possible values of lgive a very small contribution to the current, and it becomes minimal. At $\sigma_z = 1/2$ the current density J_{\uparrow} is only determined by electrons with l=0, so the contribution of this current component to the total current density J_t is small. With a further increase in V_a , the second resonant peak of $T_{\sigma_z}(E_z)$ intersects the line $E_{zm}^{\sigma_z}(0)$, and a second peak appears in $J_{\downarrow}(V_a)$ and $J_{\uparrow}(V_a)$. In this case, the width of the second peak of $T_{\perp}(E_z)$ is so large that it intersects practically all lines $E_{zm}^{\downarrow}(l)$ (at $V_a \ge 0.08$ V). As a result, J_{\perp} is produced by the electrons located at all the filled Landau levels. For this reason the second peak of $J_{\perp}(V_a)$ is higher and smoother than the first one, and it does not contain visible kinks. Note that the value of the second peak of J_{\uparrow} approximately equals to the value of the first peak.

Let us denote the resonant peak locations of $T_{\sigma_z}(E_z)$ by $E_{zp}^{\sigma_z}$. Figure 6 shows the dependencies of $E_{zp}^{\sigma_z}(V_a)$ for the first two peaks of $T_{\downarrow}(E_z)$ (solid lines) and $T_{\uparrow}(E_z)$ (dashed lines) for B=4 T, $E_F=10$ meV, and $x_3=0.0$. It is seen from this figure that the first and second resonant peaks of $T_{\downarrow}(E_z)$ are located in the region of smaller values of E_z than those of $T_{\uparrow}(E_z)$. With increasing V_a , the locations of the resonant peaks of $T_{\sigma_z}(E_z)$ shift to the low-energy region. Each current density component J_{σ_z} makes a contribution to the total current density J_t for those values of V_a for which the value of $E_{zp}^{\sigma_z}$ is less than the value of $E_{zm}^{\sigma_z}(0)$. Note that the end-points of the resonant peaks in the $T_{\sigma_z}(E_z)$, i.e., these dependencies are monotone with further increase of V_a .

C. The effect of total RTD current spin polarization

It is clear that a high degree of the current spin polarization occurs when J_{\uparrow} is small. It follows from (8) that at low temperatures the current is only created by the electrons for which the condition $E_z < E_{zm}^{\sigma_z}(l)$ is fulfilled. It is obvious that



FIG. 7. $E_F(B)$ (left ordinate axis) and n(B) (right ordinate axis) corresponding to the occurrence of total current spin polarization effect.

for the spin-up electrons ($\sigma_z = 1/2$) located at the lowest Landau level (l=0), the condition $E_{zm}^{\uparrow}(0) \leq 0$ can be fulfilled. This implies that for the spin-up electrons, the lowest Landau level is located higher than the Fermi level, and spin-up electrons are absent in the RTD emitter. As a result, the effect of total spin polarization of the electron current in the RTD must occur when the current is only caused by the spin-down electrons ($J_{\uparrow}=0, P=1$).

Let us show that the condition $E_{zm}^{\uparrow}(0) \leq 0$ can be fulfilled for moderate magnetic fields B. In Fig. 7 the $E_F(B)$ dependence (solid curve 1), corresponding to the solution of equation $E_{zm}^{\uparrow}(0)=0$, is plotted along the left axis of the ordinates. The magnetic field dependence of the RTD emitter electron concentration n (dashed curve 2) is presented along the right axis of the ordinates assuming that n is related to E_F by the equation $n = (1/3\pi^2)(2m^*E_F/\hbar^2)^{3/2}$. (We consider the electron gas in the RTD emitter to be degenerate.) For a fixed value of E_F , the effect of the total spin polarization of the electron current must occur starting at a critical value of B. (This situation corresponds to the dashed area in Fig. 7.) Note that in order to decrease the critical value of B, it is necessary to decrease the value of E_F . For example, for the moderate value B=2 T the effect of the total spin polarization of the electron current occurs at $E_F = 5.1$ meV. (The corresponding value of *n* is 10^{17} cm⁻³.)

Now we consider the influence of constant magnetic field *B* on the $J_t(V_a)$ and $P(V_a)$ for two values of the Mn concentration x_3 in the RTD quantum well at $E_F=5.1$ meV. In Fig. 8 $J_t(V_a)$ (the left axis of ordinates, curves of different types except dashed lines) and $P(V_a)$ (the right axis of ordinates, dashed lines) are shown for (a) $x_3=0.0$ and (b) $x_3=0.05$ for five different values of B=0.5,1,2,3,4 T. It is seen from Fig. 8 that with increasing *B* the current density J_t in the RTD increases, and kinks on the first resonant peak of J_t arise. The value of *P* also increases with increasing *B*. Starting with B=2 T, the electron current in the RTD is totally spin polarized (P=1). As one can see in Fig. 8(a), in the case $x_3=0.0$ the peaks of the $J_t(V_a)$ coincide with the peaks of $P(V_a)$. For the case $x_3=0.05$ [Fig. 8(b)] the situation is different because



FIG. 8. $J_t(V_a)$ (the left axis of ordinates) and P(V-a) (the right axis of ordinates) for five values of B=0.5,1,2,3,4 T, $E_F=5.1$ meV at (a) $x_3=0.0$ and (b) $x_3=0.05$.

the peak values of the current density correspond to the local minima of P. So, we conclude that in moderately low magnetic fields B, the maximal degree of the current spin polarization in the peak values of the current takes place when the RTD quantum well does not contain Mn ions. In this case the first current density peak is characterized by almost total current spin polarization.

In order to obtain a high value of the spin-polarized current in the RTD, it is necessary to increase E_F . Figure 9 shows $J_t(V_a)$ (the left axis of ordinates, curves of different types except dashed lines) and $P(V_a)$ (the right axis of ordinates, dashed lines) at (a) $x_3=0.0$ and (b) $x_3=0.05$ for five different values of $E_F=5.1,10,15,20,25$ meV at B=2 T. It is seen from Fig. 9 that with increasing E_F the current density peak values increase. However, the value of P decreases and, moreover, the function P becomes negative in low-voltage region for the case $x_3=0.05$ [Fig. 9(b)]. The first current density peak is characterized by the high value of P for the case $x_3=0.0$ as usual, but the difference in P for the second peak in cases $x_3=0.0$ and $x_3=0.05$ becomes smaller. Note that the high value of the peak-to-valley ratio typical of the first current density peak also decreases with increasing E_F .



FIG. 9. $J_t(V_a)$ (the left axis of ordinates) and $P(V_a)$ (the right axis of ordinates) for five values of E_F =5.1,10,15,20,25 meV, B=2 T at (a) x_3 =0.0 and (b) x_3 =0.05.

IV. CONCLUSION

In this paper, we have investigated theoretically the spinpolarized electron current in a double-barrier semimagnetic RTD based entirely on a $Zn_{1-x}Mn_xSe$ semimagnetic semiconductor. We have demonstrated the dependance of the current spin polarization on the external constant magnetic field, the applied voltage bias, and the distribution of Mn ions in the RTD. We have obtained the condition for total current spin polarization in the semimagnetic RTD, and we have found the optimal distribution of Mn ions in the RTD providing the maximal current spin polarization in the current peaks for arbitrary values of the external magnetic fields and the Fermi levels in the RTD emitter. We have demonstrated that the degree of current spin polarization in the semimagnetic RTD can be effectively controlled by an electric field, and this fact can be used for creating the voltage controlled sources of spin polarized current for spintronics devices.

Note that some important nonlinear phenomena related to the current transmission through the RTD have not been considered in this paper. We have neglected a charge accumulation in the quantum well which involves a band bending. This effect results in a number of interesting phenomena in conventional electron transport through RTD, such as bistability,^{18–24} tristability,²⁵ and formation of the electric field domains.²⁶ Charge accumulation in quantum wells also plays an important role in spin-polarized electron transport through the magnetic RTD.^{27,28}

In our case, the potential profile in the RTD will differ from the profile shown in Fig. 3 due to the presence of the charge accumulation in the quantum well. As a result of this the bias-voltage dependence of the resonant peak locations of $T_{\sigma_z}(E_z)$ (Fig. 6) will have a more complicated shape. This will change the positions of current peaks and the coefficient of current spin polarization *P*.

At the same time the results of our investigations show that high values of P are observed at small currents in the RTD ($J_t \approx 10 \text{ kA/cm}^2$, Fig. 9) when $E_F = 5-10 \text{ meV}$. For such small currents and small quantum well thicknesses we assume that the effects of charge accumulation and band bending are of little importance, and so we can use our results as a first approximation to the spin-filtering effect of the electron current in the semimagnetic RTD.

ACKNOWLEDGMENTS

We are grateful to G. D. Doolen for useful discussions. This work was supported by the Department of Energy (DOE) under Contract No. W-7405-ENG-36, by the National Security Agency (NSA), by the Advanced Research and Development Activity (ARDA), and by the Defense Advanced Research Projects Agency (DARPA).

- ¹R. Wessel, L. D. Vagner, Superlattices Microstruct. **8**, 443 (1990).
- ²V. A. Chitta, M. Z. Maialle, S. A. Leao, and M. H. Degani, Appl. Phys. Lett. **74**, 2845 (1999).
- ³A. Slobodskyy, C. Gould, T. Slobodskyy, C. R. Becker, G. Schmidt, and L. W. Molenkamp, Phys. Rev. Lett. **90**, 246601 (2003).
- ⁴J. C. Egues, Phys. Rev. Lett. **80**, 4578 (1998).
- ⁵Y. Guo, H. Wang, B.-L. Gu, and Y. Kawazoe, J. Appl. Phys. **88**, 6614 (2000).
- ⁶Y. Guo, B.-L. Gu, H. Wang, and Y. Kawazoe, Phys. Rev. B 63,

214415 (2001).

- ⁷Y. Guo, J.-Q. Lu, Z. Zeng, Q. Wang, B.-L. Gu, and Y. Kawazoe, Phys. Lett. A **284**, 205 (2001).
- ⁸J. C. Egues, C. Gould, G. Richter, and L. W. Molenkamp, Phys. Rev. B **64**, 195319 (2001).
- ⁹J. K. Furdyna, J. Appl. Phys. **64**, R29 (1988).
- ¹⁰O. Goede, and W. Heimbrodt, Phys. Status Solidi B 146, 11 (1988).
- ¹¹Eunsoon Oh, D. U. Bartholomew, A. K. Ramdas, J. K. Furduna, and U. Debska, Phys. Rev. B 44, 10 551 (1991).
- ¹²R. Fiederling, M. Keim, G. Reuscher, W. Ossau, G. Schmidt, A.

Waag, and L. W. Molenkamp, Nature (London) **402**, 787 (1999).

- ¹³B. T. Jonker, Y. D. Park, B. R. Bennett, H. D. Cheong, G. Kioseoglou, and A. Petrou, Phys. Rev. B **62**, 8180 (2000).
- ¹⁴P. J. Klar, D. Wolverson, J. J. Davies, W. Heimbrodt, and M. Happ, Phys. Rev. B **57**, 7103 (1998).
- ¹⁵R. B. Bylsma, W. M. Becker, J. Kossut, U. Debska, and D. Yoder-Short, Phys. Rev. B **33**, 8207 (1986).
- ¹⁶A. A. Toropov, A. V. Lebedev, S. V. Sorokin, D. D. Solnyshkov, S. V. Ivanov, P. S. Kopev, I. A. Buyanova, W. M. Chen, and B. Monemar, Semiconductors **36**, 1288 (2002).
- ¹⁷S. Vatannia, and G. Gindenblat, IEEE J. Quantum Electron. **32**, 1093 (1996).
- ¹⁸V. J. Goldman, D. C. Tsui, and J. E. Cunningham, Phys. Rev. Lett. **58**, 1256 (1987).
- ¹⁹T. C. L. G. Sollner, Phys. Rev. Lett. **59**, 1622 (1987).
- ²⁰ V. J. Goldman, D. C. Tsui, and J. E. Cunningham, Phys. Rev. B 35, 9387 (1987).

- ²¹F. W. Sheard and G. A. Toombs. Appl. Phys. Lett. **52**, 1228 (1988).
- ²²M. L. Leadbeater, E. S. Alves, L. Eaves, M. Henini, O. H. Hughes, F. W. Sheard, and G. A. Toombs, Semicond. Sci. Technol. **3**, 1060 (1988).
- ²³A. Zaslavsky, V. J. Goldman, D. C. Tsui, and J. E. Gunningham Appl. Phys. Lett. **53**, 1408 (1988).
- ²⁴D. G. Hayes, M. S. Skolnick, P. E. Simmonds, L. Eaves, D. P. Halliday, M. L. Leadbeater, M. Henini, O. H. Hughes, G. Hill, and M. A. Pate, Surf. Sci. **228**, 373 (1990).
- ²⁵A. D. Martin, M. L. F. Lerch, P. E. Simmonds, and L. Eaves, Appl. Phys. Lett. **64**, 1248 (1994).
- ²⁶B. A. Glavin, V. A. Kochelap, and V. V. Mitin, Phys. Rev. B 56, 13 346 (1997).
- ²⁷M. Zervosa, J. Appl. Phys. **94**, 1776 (2003).
- ²⁸D. Sanchez, A. H. Macdonald, and G. Platero, Physica E (Amsterdam) 13, 525 (2002).